

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 7,176,118 B2  
APPLICATION NO. : 10/810779  
DATED : February 13, 2007  
INVENTOR(S) : Cem Basceri et al.

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Col. 2, line 30 –

Replace “FIG. 2 is view of the FIG. 1 wafer fragment shown at a”  
With --FIG. 2 is a view of the FIG. 1 wafer fragment shown at a --

Col. 3, line 2 –

Replace “from the fluid, The chemical reaction can be selective for an”  
With --from the fluid. The chemical reaction can be selective for an--

Col. 3, line 15 –

Replace “new patterning methods are utilized to form nanodevices,”  
With --new patterning methods are utilized to form nanodevices,--

Col. 7, line 13 –

Replace “FIG. 7 is an a sense an opposite to that described with”  
With --FIG. 7 is in a sense an opposite to that described with--

Signed and Sealed this

Twelfth Day of June, 2007



JON W. DUDAS  
*Director of the United States Patent and Trademark Office*